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APPLICATION NO.	FILING DATE	FIRST NAMED INVENTOR	ATTORNEY DIX'KET NO.	CONFIRMATION NO.
10/068,283	02/05/2002	Axel Scherer	CIT.PAU.01	9733
21	7590 06-07/2004		EXAMINER	
Daniel L. Day	ves		MCDONALD, RO	DDNEY GLENN
MYERS, DAW	ES & ANDRAS LLP		ART UNIT	PAPER NUMBER
Irvine, CA 92	nur Blvd, Ste 1150 2612		1753	

DATE MAILED: 06/07/2004

Please find below and/or attached an Office communication concerning this application or proceeding.

	Application No.	Applicant(s)
	10/068,283	SCHERER ET AL.
Office Action Summary	Examiner	Art Unit
	Rodney G. McDonald	1753
The MAILING DATE of this communication Period for Reply	on appears on the cover sheet w	vith the correspondence address
A SHORTENED STATUTORY PERIOD FOR ITHE MAILING DATE OF THIS COMMUNICAT Extensions of time may be available under the provisions of 37 after SIX (6) MONTHS from the mailing date of this communicat If the period for reply specified above is less than thirty (30) day If NO period for reply is specified above, the maximum statutory Failure to reply within the set or extended period for reply will, by Any reply received by the Office later than three months after the earned patent term adjustment. See 37 CFR 1.704(b).	TION. CFR 1,136(a). In no event, however, may a tion. s, a reply within the statutory minimum of thi period will apply and will expire SIX (6) MOI statute, cause the application to become A	reply be timely filed rty (30) days will be considered timely. NTHS from the mailing date of this communication. BANDONED (35 U.S.C. & 133)
Status		
	10 April 2004	
1) Responsive to communication(s) filed or 2a) This action is FINAL . 2b) 2b) 2b	This action is non-final.	
3) Since this application is in condition for a	='	ters prosecution as to the merits is
closed in accordance with the practice u	•	·
	,	
Disposition of Claims		
4) Claim(s) <u>1-15 and 21-25</u> is/are pending i		
4a) Of the above claim(s) is/are wi		
5) Claim(s) <u>2,3,5,6 and 8-15</u> is/are allowed.		
6) Claim(s) <u>1,4,7 and 21-25</u> is/are rejected.		
7) Claim(s) is/are objected to. 8) Claim(s) are subject to restriction	and/or election requirement	
order (a)	and/or clossoff requirement.	
Application Papers		
9)☐ The specification is objected to by the Ex	aminer.	
10) The drawing(s) filed on is/are: a)	☐ accepted or b)☐ objected to	by the Examiner.
Applicant may not request that any objection	to the drawing(s) be held in abeya	nce. See 37 CFR 1.85(a).
Replacement drawing sheet(s) including the	· · · · · · · · · · · · · · · · · · ·	• • • • • • • • • • • • • • • • • • • •
11) The oath or declaration is objected to by	the Examiner. Note the attache	d Office Action or form PTO-152.
Priority under 35 U.S.C. § 119		
12) Acknowledgment is made of a claim for fo	oreign priority under 35 U.S.C.	§ 119(a)-(d) or (f).
a)□ All b)□ Some * c)□ None of:		
1. Certified copies of the priority docu		
2. Certified copies of the priority docu		
3. Copies of the certified copies of th		received in this National Stage
application from the International E		Lucanii sad
* See the attached detailed Office action for	a list of the certified copies not	received.
Attachment(s)	∧ □	0
 Notice of References Cited (PTO-892) Notice of Draftsperson's Patent Drawing Review (PTO-9-9-1) 		Summary (PTO-413) s)/Mail Date
3) Information Disclosure Statement(s) (PTO-1449 or PTO/ Paper No(s)/Mail Date		Informal Patent Application (PTO-152)

Art Unit: 1753

DETAILED ACTION

Continued Examination Under 37 CFR 1.114

A request for continued examination under 37 CFR 1.114, including the fee set forth in 37 CFR 1.17(e), was filed in this application after final rejection. Since this application is eligible for continued examination under 37 CFR 1.114, and the fee set forth in 37 CFR 1.17(e) has been timely paid, the finality of the previous Office action has been withdrawn pursuant to 37 CFR 1.114. Applicant's submission filed on April 19, 2004 has been entered.

Claim Rejections - 35 USC § 112

Claims 1 and 21-25 are rejected under 35 U.S.C. 112, first paragraph, as failing to comply with the written description requirement. The claim(s) contains subject matter which was not described in the specification in such a way as to reasonably convey to one skilled in the relevant art that the inventor(s), at the time the application was filed, had possession of the claimed invention.

Specifically with respect to claim 1 the formation of "masking layers" on the silicone elastomer is not discussed in the specification. There is only the mention of Utilizing a "photoresist" on the reactively sputtered silicon dioxide layer or utilizing mask deposition on the additional layers reactively sputtered on the silicon dioxide layer. This appears to be only single masking layers. (See Applicant's specification Page 6 lines 1-8)

Additionally with respect to claims 21-25 directionally etching an elastomeric material in combination with the utilizing reactive sputter deposition to form masking

Application/Control Number: 10/068,283

Art Unit: 1753

layers by means of which the three dimensional structure is photolithographically microfabricated in the elastomeric material is not discussed in Applicant's specification.

Claims 1, 4, 7 and 21-25 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

Claim 1, line 5, "sputtering" should be "sputter".

Claim 1, line 6, "therein" should be "thereon".

Claim 4, line 6, "laver" should be "layer".

Claim 4, line 6, "6elastomeric" should be "elastomeric".

Claim 4, line 7 "by." should be "by".

Claim 7, line 3, "3argon-nitrogen" should be "argon-nitrogen".

Allowable Subject Matter

Claims 4 and 7 would be allowable if rewritten to overcome the rejection(s) under 35 U.S.C. 112, second paragraph, set forth in this Office action.

Claims 2, 3, 5, 6 and 8-15 are allowed.

The following is a statement of reasons for the indication of allowable subject matter:

Claims 2-15 are indicated as being allowable over the prior art of record because the prior art of record does not teach forming silicon dioxide, silicon nitride or silicon on an elastomeric material for decreasing the surface tension of the elastomeric material and photolithographically processing the elastomeric with the decreased surface tension.

Application/Control Number: 10/068,283

Art Unit: 1753

Any inquiry concerning this communication or earlier communications from the examiner should be directed to Rodney G. McDonald whose telephone number is 571-272-1340. The examiner can normally be reached on M- Th with Every other Friday off.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Nam X. Nguyen can be reached on 571-272-1342. The fax phone number for the organization where this application or proceeding is assigned is 703-872-9306.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free).

Rodney G. McDonald Primary Examiner Art Unit 1753

RM June 3, 2004